In-situ TEM Experiments to Assess the Predictive Capability of Atomistic models

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In-situ microscopy testing empowered with the versatility of microelectromechanical systems (MEMS) has played a vital role in unveiling structure-property relationships. We developed a MEMS-based nanoscale-Material Testing system (n-MTS) [1-2], which interfaces with electron microscopes to perform *in situ* mechanical and electromechanical testing of one-dimensional nanostructures. In this set-up, the quantitative load-displacement data is acquired electronically and the specimen is monitored with atomic-level resolution during the test. Uniaxial loading condition is maintained which facilitates data interpretation with minimal assumptions. This unique set-up was used to investigate carbon nanotubes (CNTs) and semiconducting nanowires (NWs), in turn providing an assessment of existing predictive capabilities of the atomistic models.

In-situ TEM, multi-walled carbon nanotubes (MWNTs) subjected to various degrees of electron and ion irradiation were mechanically tested [3-4]. We observed that below a threshold radiation, the MWNTs failed by a telescopic or "sword-in-sheath" mechanism. Analysis of the high resolution TEM images clearly revealed the number of shells fractured. For an experiment, where just one shell failed, a Young's modulus of 998 GPa and a failure stress of 97 GPa were measured, which is in good agreement with values predicted by Density Functional Theory (DFT) calculations for pristine single-walled CNTs. These results were the first of their kind allowing for a direct comparison with the theoretical predictions, validating the approximations involved in modeling. In addition to mechanical characterization of MWNTs, elasticity size effects and failure mechanisms in zinc oxide (ZnO) NWs were also investigated using a combined experimental-computational approach. In-situ TEM experiments resolved the discrepancy concerning size dependent elastic modulus of ZnO NWs, revealing increasing elastic modulus with decreasing wire diameter [5]. Molecular dynamics (MD) simulations using a Buckingham type potential predicted a trend consistent with the experimental findings. However, the failure mechanisms observed in experiments and simulations were different. The experiments revealed brittle fracture whereas MD simulations predicted a phase transformation, which casted doubts on the accuracy of Buckingham type potential in capturing the phenomena of fracture [6]. Therefore, first-principles based calculations are being pursued to validate the accuracy of the MD force fields for predicting failure modes. We are also involved in characterizing the electromechanical coupling and measuring the piezoelectric coefficients in gallium nitride nanowires as a function of their characteristic size. Preliminary results suggest there might be an enhancement in piezoelectric properties of smaller nanowires.

References

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